

Logistics

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 - ◆ (.pdf's but probably not all .ppt's)
- "Tutorial end" with Section V, ~5:00pm
- Continue with questions until ???

Section I: Introduction

Schedule

- 10:00 – 10:45 I: Introduction
 - ☞ Technology roadmap implications, baseline flat methodology, problem motivations (SI, timing closure)
- 10:45 – 11:45 II: Basic Issues
 - ☞ Hierarchy, data prep, packaging, tool selection, tapeout issues, implications of test / pad layout / verification / library / clocking choices
- 11:45 – 12:30 III: Partitioning and Floorplanning
 - ☞ Partitioning into P&R blocks, block-level floorplanning, area I/O vs. peripheral I/O, clock distribution
- 12:30 – 1:30 LUNCH

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Schedule

- 1:30 – 2:30 III: Partitioning and Floorplanning cont.
- 2:30 – 3:45 IV: Timing Closure Techniques
 - ☞ Integrated timing/synthesis/placement/wiring for ASIC design, placement algorithms, congestion management, use of timing-driven features, timing and routability convergence
- 3:45 – 4:00 Coffee Break
- 4:00 – 5:00 V: Analysis and Verification
 - ☞ Manufacturability, inductance modeling, IR drop and ground bounce, power analysis and decoupling, signoff timing verification, special LVS/DRC issues
- 5:00 – 5:30 VI: Other Topics
 - ☞ Test, formal verification, vendor / tool gossip, your call (based on questionnaire feedback during lunch)...

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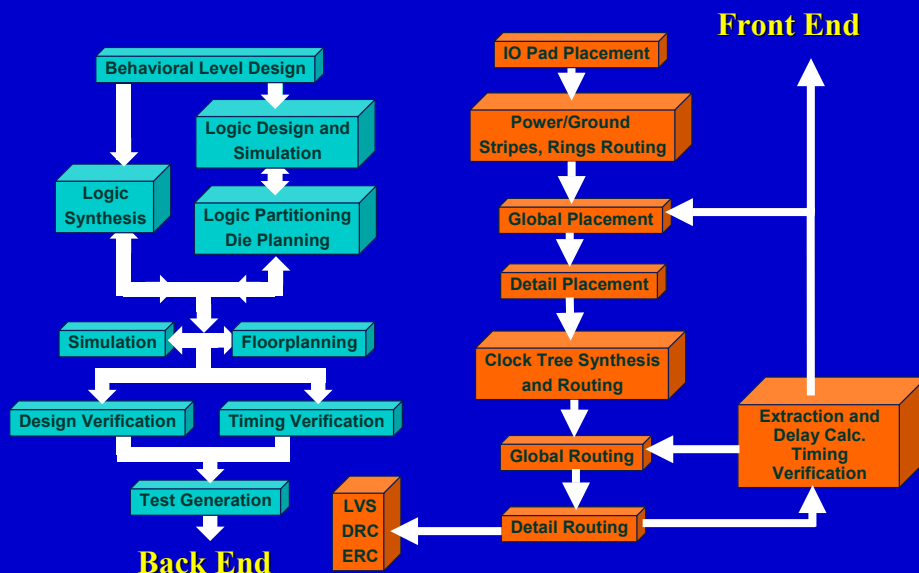
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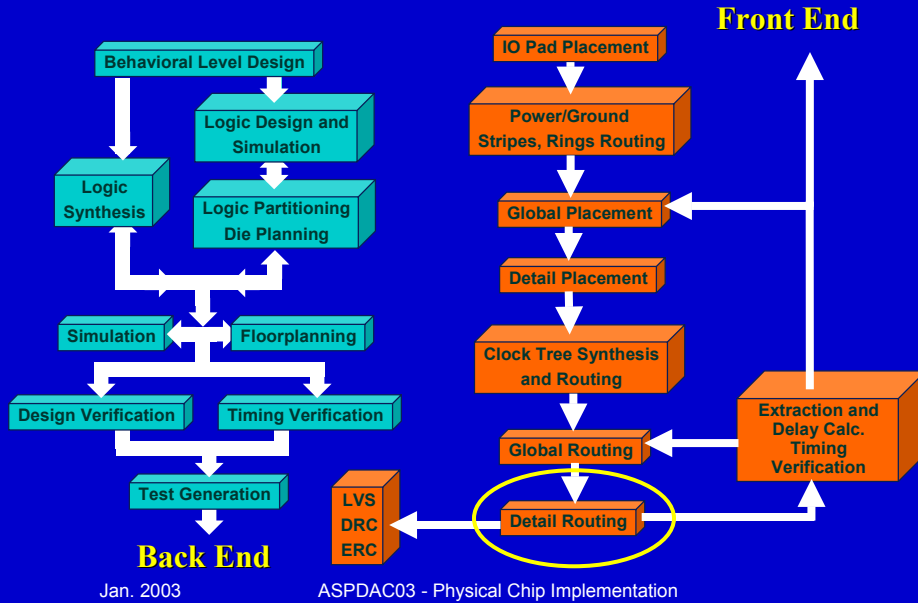
Overview

- Introduction
- Technology roadmap
- Design convergence approaches

Traditional Flow

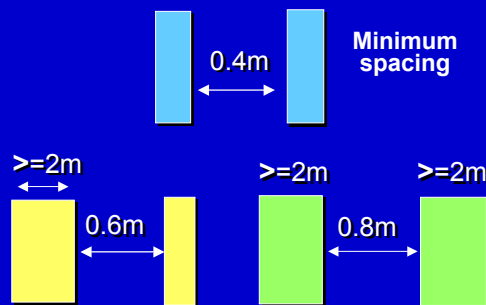


Example Difficulty: Detail Routing



Width / Spacing Rules

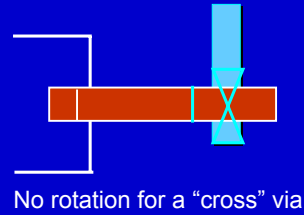
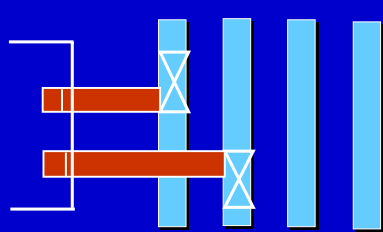
- Per connection, per net, per class, ...



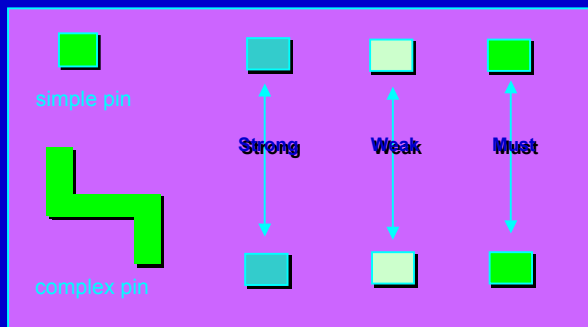
Width-based Spacing

Via Selection

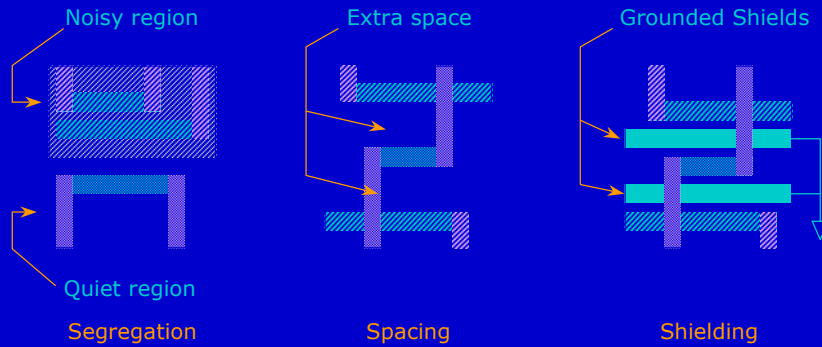
- Via array based on wire size or resistance
- Rectangular via rotation and offset



Complex Pins, Equivalent Pin Modeling



Noise-Driven

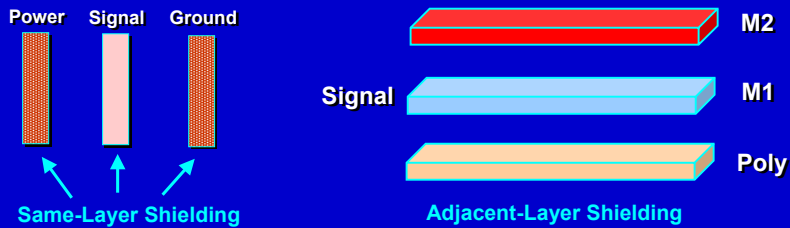


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Same-Layer, Adj-Layer Shielding

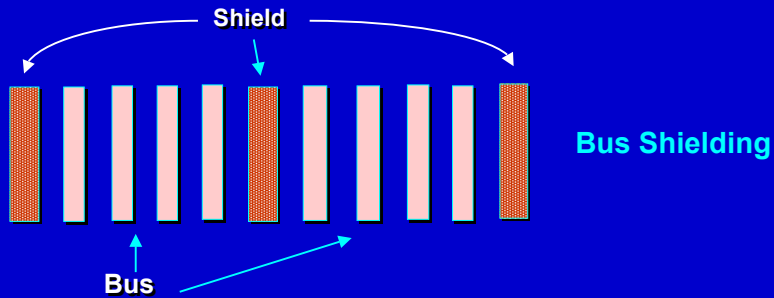


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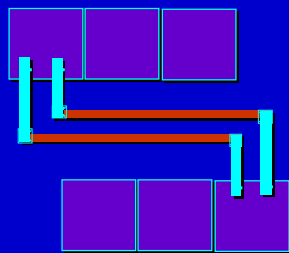
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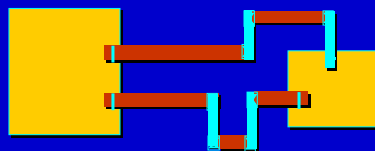
Bus Shielding and Interleaving



Differential-Pair, Balanced (length, cap) Routes

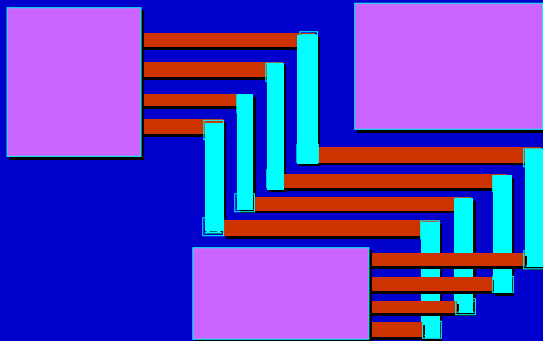


Differential



Balanced length

Bus Routers

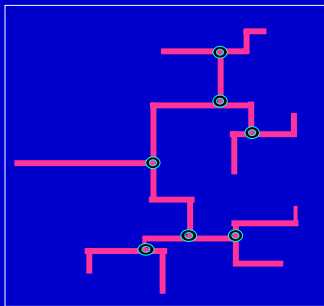


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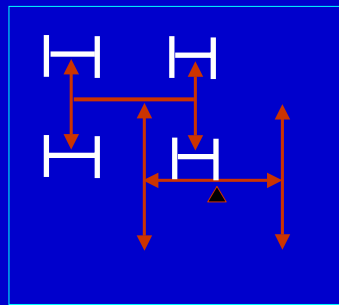
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Clock Routers



Balanced Tree



H-Tree

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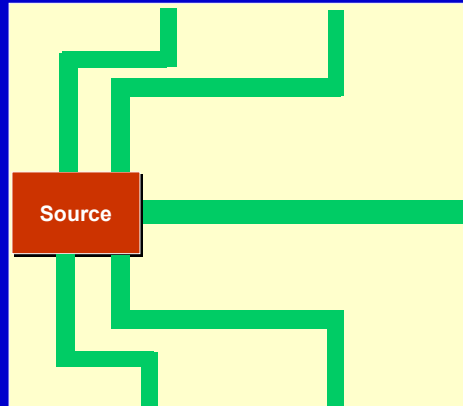
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Power Routers

- Power Mesh
- Power Ring
- Star Routing
- Grounded Fill

Star Routing →

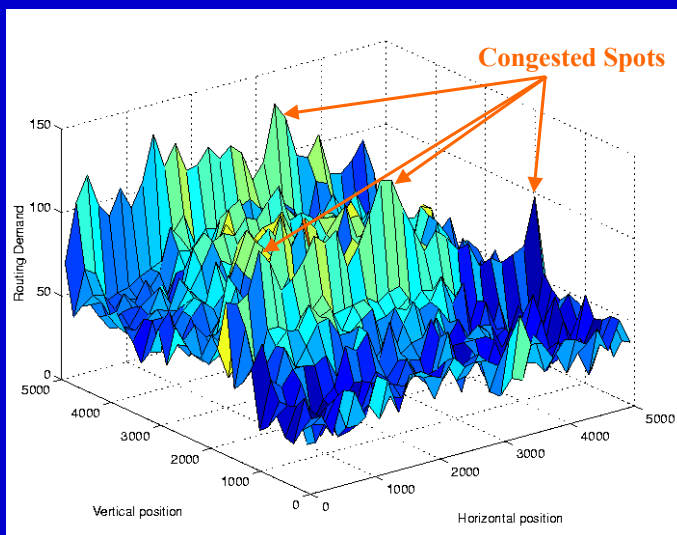


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Congestion

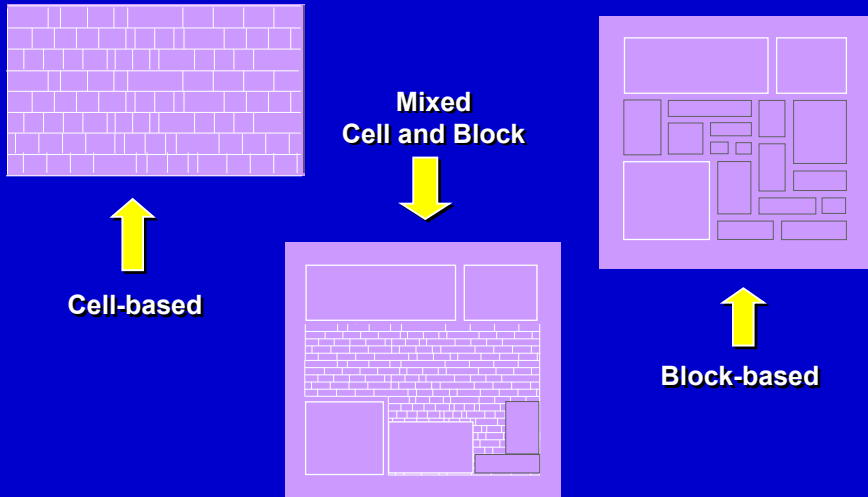


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Different Applications

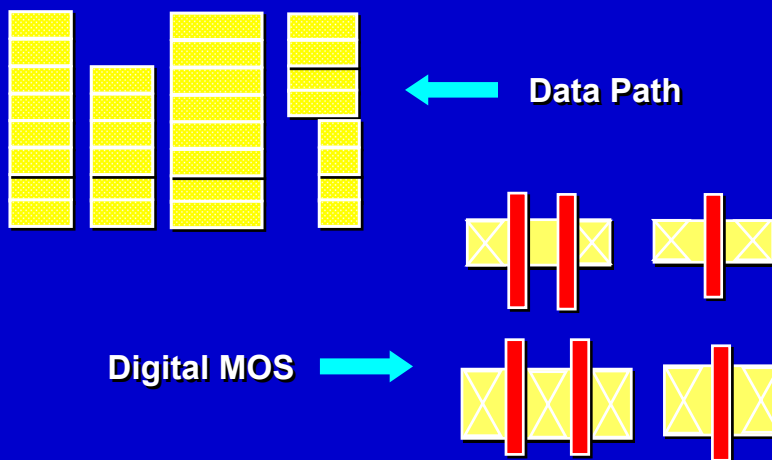


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Different Applications



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And More...

- Other rules
 - ◆ Process antenna, phase shift mask, OPC rules
- Frameworks
 - ◆ Channel routing
 - ◆ Switch box routing
 - ◆ Maze routing
 - ◆ Line probe routing
 - ◆ Shape-based routing
 - ◆ Fixed die vs. variable die
 - ◆ Gridded vs. gridless
- This tutorial: Issues, choices (which define methodologies)

Technology Roadmap

Roadmap Changes Since 2000

- Next “node” = 0.7x half-pitch or minimum feature size
 - ◆ → 2x transistors on the same size die
- 90nm node in 2004 (100nm in 2003)
 - ◆ 90nm node → physical gate length = 45nm
- MPU/ASIC half-pitch = DRAM half-pitch in 2004
 - ◆ Previous ITRS (2000): convergence in 2015
- Psychology: everyone must beat the Roadmap
 - ◆ Reasons: density, cost reduction, competitive position
 - ◆ TSMC CL010G logic/mixed-signal SOC process: risk production in 4Q02 with multi-Vt, multi-oxide, embedded DRAM and flash, low standby power derivatives, ...

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Red Brick Wall - 2001 ITRS vs 1999



Table 1. 2001 Status of Red Brick Wall							
Year of production	2001	2003	2005		2007	2010	2016
DRAM half-pitch (nm)	130	100	80		65	45	22
Overlay accuracy (nm)	46	35	28		23	18	9
MPU gate length (nm)	90	65	45		35	25	13
CD control (nm)	8	5.5	3.9		3.1	2.2	1.1
T _{ox} (equivalent) (nm)	1.3-1.6	1.1-1.6	0.8-1.3		0.6-1.1	0.5-0.8	0.4-0.5
Junction depth (nm)	48-95	33-66	24-47		18-37	13-26	7-13
Metal cladding thickness (nm)	16	12	9		7	5	2.5
Intermetal dielectric constant, k	3.0-3.6	3.0-3.6	2.6-3.1		2.3-2.7	2.1	1.8

Table 2. 1999 Status of Red Brick Wall							
Year of production	1999	2002	2005		2008	2011	2014
DRAM half-pitch (nm)	180	130	100		70	50	35
Overlay accuracy (nm)	65	45	35		25	20	15
MPU gate length (nm)	140	85-90	65		45	30-32	20-22
CD control (nm)	14	9	6		4	3	2
T _{ox} (equivalent) (nm)	1.9-2.5	1.5-1.9	1.0-1.5		0.8-1.2	0.6-0.8	0.5-0.6
Junction depth (nm)	42-70	25-43	20-33		16-26	11-19	8-13
Metal cladding thickness (nm)	17	13	10		0	0	0
Intermetal dielectric constant, k	3.5-4.0	2.7-3.56	1.6-2.2		1.5	<1.5	<1.5

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Source: Semiconductor International - <http://www.e-insite.net/semiconductor/index.asp?layout=article&articleId=CA187876>

Roadmap Acceleration and Deceleration

2001 versus 1999 Results

Year of Production:	1999	2002	2005	2008	2011	2014
DRAM Half-Pitch [nm]:	180	130	100	70	50	35
Overlay Accuracy [nm]:	65	45	35	25	20	15
MPU Gate Length [nm]:	140	85-90	65	45	30-32	20-22
CD Control [nm]:	14	9	6	4	3	2
T _{ox} (equivalent) [nm]:	1.9-2.5	1.5-1.9	1.0-1.5	0.8-1.2	0.6-0.8	0.5-0.6
Junction Depth [nm]:	42-70	25-43	20-33	16-26	11-19	8-13
Metal Cladding [nm]:	17	13	10			0.0
Inter-Metal Dielectric K:	3.5-4.0		2.7-3.5		1.6-2.2	1.5

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A. Allan, Intel

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HP / LOP / LSTP Device Roadmaps

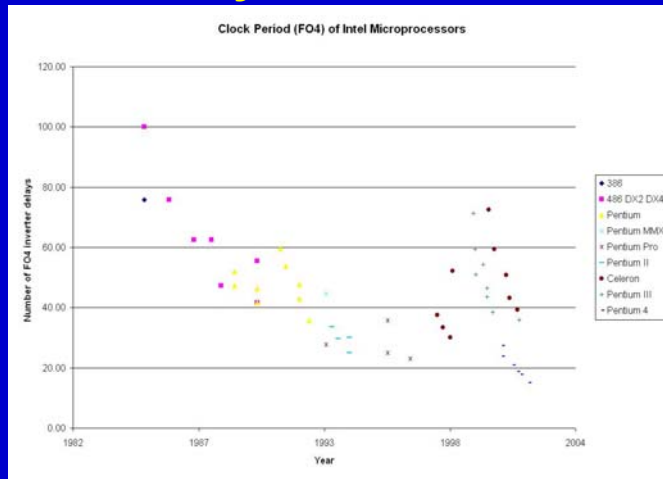
Parameter	Type	99	01	03	05	07	10	13	16
V _{dd}	MPU	1.5	1.2	1.0	0.9	0.7	0.6	0.5	0.4
	LOP	1.3	1.2	1.1	1.0	0.9	0.8	0.7	0.6
	LSTP	1.3	1.2	1.2	1.2	1.1	1.0	0.9	0.9
V _{th} (V)	MPU	0.21	0.19	0.13	0.09	0.05	0.021	0.003	0.003
	LOP	0.34	0.34	0.36	0.33	0.29	0.29	0.25	0.22
	LSTP	0.51	0.51	0.53	0.54	0.52	0.49	0.45	0.45
I _{on} (uA/um)	MPU	1041	926	967	924	1091	1250	1492	1507
	LOP	636	600	600	600	700	700	800	900
	LSTP	300	300	400	400	500	500	600	800
CV/I (ps)	MPU	2.00	1.63	1.16	0.86	0.66	0.39	0.23	0.16
	LOP	3.50	2.55	2.02	1.58	1.14	0.85	0.56	0.35
	LSTP	4.21	4.61	2.96	2.51	1.81	1.43	0.91	0.57
I _{off} (uA/um)	MPU	0.00	0.01	0.07	0.30	1.00	3	7	10
	LOP	1e-4	1e-4	1e-4	3e-4	7e-4	1e-3	3e-3	1e-2
	LSTP	1e-6	1e-6	1e-6	1e-6	1e-6	3e-6	7e-6	1e-5

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FO4 INV Delays Per Clock Period



- FO4 INV = inverter driving 4 identical inverters (no interconnect)
- Half of freq improvement has been from reduced logic stages

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Silicon Complexity Challenges

- Silicon Complexity = impact of process scaling, new materials, new device/interconnect architectures
- Non-ideal scaling (leakage, power management, circuit/device innovation, current delivery)
- Coupled high-frequency devices and interconnects (signal integrity analysis and management)
- Manufacturing variability (library characterization, analog and digital circuit performance, error-tolerant design, layout reusability, static performance verification methodology/tools)
- Scaling of global interconnect performance (communication, synchronization)
- Decreased reliability (SEU, gate insulator tunneling and breakdown, joule heating and electromigration)
- Complexity of manufacturing handoff (reticle enhancement and mask writing/inspection flow, manufacturing NRE cost)

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System Complexity Challenges

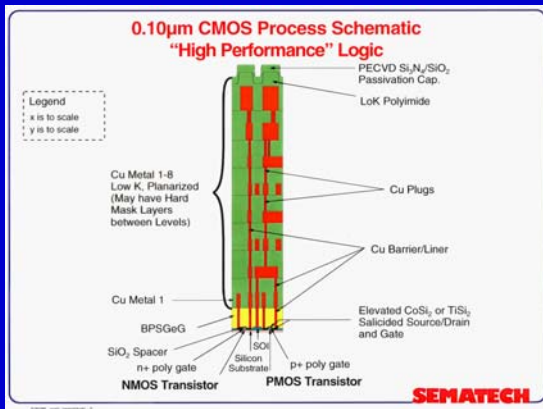
- System Complexity = exponentially increasing transistor counts, with increased diversity (mixed-signal SOC, ...)
- Reuse (hierarchical design support, heterogeneous SOC integration, reuse of verification/test/IP)
- Verification and test (specification capture, design for verifiability, verification reuse, system-level and software verification, AMS self-test, noise-delay fault tests, test reuse)
- Cost-driven design optimization (manufacturing cost modeling and analysis, quality metrics, die-package co-optimization, ...)
- Embedded software design (platform-based system design methodologies, software verification/analysis, codesign w/HW)
- Reliable implementation platforms (predictable chip implementation onto multiple fabrics, higher-level handoff)
- Design process management (team size / geog distribution, data mgmt, collaborative design, process improvement)

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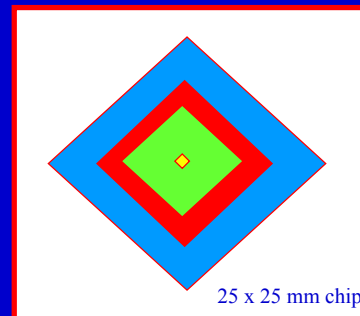
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Reachability



Reachability in $t_{\text{crit}} = 80 \text{ ps}$



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Summary of Technology Scaling

- Scaling of 0.7x every three (two?) years
 - ◆ .25u .18u .13u .10u .07u .05u
 - ◆ 1997 1999 2002 2005 2008 2011
 - ◆ 5LM 6LM 7LM 7LM 8LM 9LM
- Interconnect delay dominates system performance
 - ◆ consumes 70% of clock cycle
- Cross coupling capacitance is dominating
 - ◆ cross capacitance → 100%, ground capacitance → 0%
 - ◆ 90% in .18u
 - ◆ huge signal integrity implications (e.g., guardbands in static analysis approaches)
- Multiple clock cycles required to cross chip
 - ◆ whether 3 or 15 not as important as fact of “multiple” > 1

New Materials Implications

- Lower dielectric permittivity
 - ◆ reduces total capacitance
 - ◆ doesn't change cross-coupled / grounded capacitance proportions
- Copper metallization
 - ◆ reduces RC delay
 - ◆ avoids electromigration (factor of 4-5 ?)
 - ◆ thinner deposition reduces cross cap
- Multiple layers of routing
 - ◆ enabled by planarization; 10% extra cost per layer
 - ◆ reverse-scaled top-level interconnects
 - ◆ relative routing pitch may increase
 - ◆ room for shielding

Technical Issues

- Manufacturability (chip can't be built)
 - ◆ antenna rules
 - ◆ minimum area rules for stacked vias
 - ◆ CMP (chemical mechanical polishing) area fill rules
 - ◆ layout corrections for optical proximity effects in subwavelength lithography; associated verification issues
- Signal integrity (failure to meet timing targets)
 - ◆ crosstalk induced errors
 - ◆ timing dependence on crosstalk
 - ◆ IR drop on power supplies
- Reliability (design failures in the field)
 - ◆ electromigration on power supplies
 - ◆ hot electron effects on devices
 - ◆ wire self heat effects on clocks and signals

Noise

- Analog design concerns are due to physical noise sources
 - ◆ because of discreteness of electronic charge and stochastic nature of electronic transport processes
 - ◆ example: thermal noise, flicker noise, shot noise
- Digital circuits due to large, abrupt voltage swings, create deterministic noise which is several orders of magnitude higher than stochastic physical noise
 - ◆ still digital circuits are prevalent because they are inherently immune to noise
- Technology scaling and performance demands make noisiness of digital circuits a big problem

Design Convergence Approaches and Issues

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Goal: Design Convergence

- What must converge ?
 - ◆ logic, timing, and spatial embedding
 - ◆ support front-end signoff with a predictable back-end
- Achieve Convergence through Predictability
 - ◆ **correct by construction (“assume, then enforce”)**
 - constraints and assumptions passed downstream; not much goes upstream
 - ignores concerns via guardbanding
 - separates concerns as able (e.g., FE logic/timing vs. BE spatial embedding)
 - ◆ **construct by correction (“tight loops”)**
 - logic-layout unification; synthesis-analysis unification, concurrent optimization
 - ◆ **elimination of concerns**
 - reduced degrees of freedom, pre-emptive design techniques
 - e.g., power distribution, layer assignment / repeater rules, GALS/LIS

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“Design Convergence Tool”

- “Silicon Virtual Prototype”, “IC Implementation Suite”
- Input
 - ◆ RT-level HDL + technology + constraints
- Output
 - ◆ “go”: recipe for invoking SP&R, composing results
 - ◆ “no go”: diagnosis of RTL code problems
- Logical and physical hierarchies co-evolve
 - ◆ spatial: top-down coarse placement → physical hierarchy
 - ◆ logic/timing: implementable RTL → logical hierarchy
 - ◆ Evolution: no-FP, phys-FP, RTL-FP, ...
- Many details (construct, predict, ignore, eliminate, ...)
 - ◆ pin optimizations, interconnect planning, hierarchy reconciliations, budgeting mechanisms, compatibility with downstream SP&R, ...

Planning Technology Elements

- RTL partitioning
 - ◆ understand interaction b/w block definition and placement quality
 - ◆ recognize and cure a physically challenged logic hierarchy
- Global interconnect planning and optimization
 - ◆ symbolic route representations to support block plan ECOs
- Controllable SP&R back end (including power/clock/scan)
- Incremental / ECO optimizations, and optimizations that are “robust” under partial or imperfect design knowledge
- Better estimators (“initial WLMs”)
 - ◆ to account for resource, topological heterogeneity
 - ◆ to account for optimizations (placement, ripup/reroute, timing)
- → “earliest RTL signoff with detailed P&R knowledge”

Taxonomy of Traditional Planning / Implementation Methodologies

- Centered on logic design
 - ◆ wire-planning methodology with block/cell global placement
 - ◆ global routing directives passed forward to chip finishing
 - ◆ constant-delay methodology may be used to guide sizing
- Centered on physical design
 - ◆ placement-driven or placement-knowledgeable logic synthesis
- Buffer between logic and layout synthesis
 - ◆ placement, timing, sizing optimization tools
- Centered on SOC, chip-level planning
 - ◆ interface synthesis between blocks
 - ◆ communications protocol, protocol implementation decisions guide logic and physical implementation

Issue: Performance Optimizations

- Design optimizations
 - ◆ global restructuring optimization -- logic optimization on layout using actual RC, noise peak values etc.
 - ◆ localized optimization -- with no structural changes and least layout impact
 - ◆ repeater/buffer insertion for global wires
- Physical optimizations
 - ◆ high fanout net synthesis (eg. for clock nets); buffer trees to meet delay/skew and fanout requirements
 - ◆ automatically determine network topology (# levels, #buffers, and type of buffers)
 - ◆ wire sizing, spacing, shielding etc.
- Fixing timing violations automatically
 - ◆ fix setup/hold time violations
 - ◆ fix maximum slew and fanout violations

Issue: Hierarchy

- Two hierarchies: logical/functional, and physical
- RTL design = logical/functional hierarchy
 - ◆ provides valuable clues for physical embedding: datapath structure, timing structure, etc.
 - ◆ can be very misleading (e.g., all clock buffers in a single hierarchy block)
- Main issues:
 - ◆ how to leverage logical/functional hierarchy during embedding
 - ◆ when to deviate from designer's hierarchy
 - ◆ methodology for hierarchy reconciliation (buffers, repartitioning / reclustering, etc.)

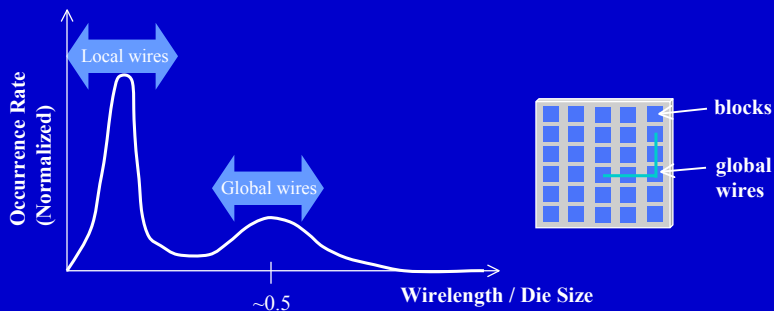
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Issue: Interconnect Complexity

- Interconnect effects play a major role in the increasing costs for large hard-block or rectilinear-outline based design styles
- Probabilistic wireload models fail
- Need "soft block" design and assembly



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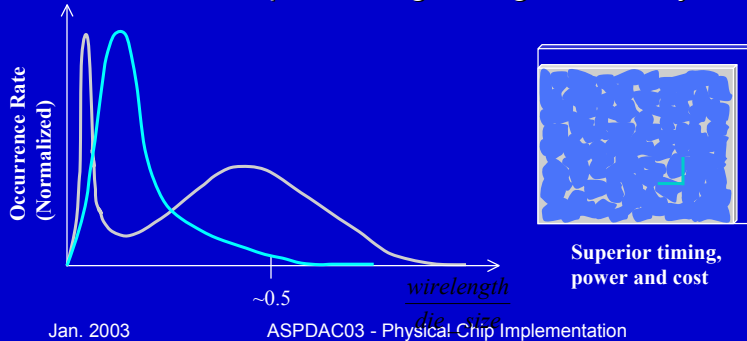
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Courtesy Pileggi, MARCO GSRC

Soft Blocks

- Flexible blocks allow system assembly to more thoroughly exploit the available technology
- Interconnect problem is controlled via: soft boundaries for area re-shaping; re-synthesis and re-mapping for timing; smart wires; and top-down specified block synthesis
- Cf. “Amoeba” placement, coloring analysis of “good” placements with respect to original logic hierarchy, etc.



Placement Directions

- Global placement
 - ◆ Engines (analytic, top-down partitioning based, (iterative annealing based) remain the same; all support “anytime” convergent solution
 - ◆ Several hybrid ideas (multilevel, force-directed, quadratic + partition)
 - ◆ Becomes more hierarchical
 - block placement, latch placement before “cell placement”
 - ◆ Supports placement of partially/probabilistically specified design
- Detailed placement
 - ◆ LEQ/EEQ substitution
 - ◆ Shifting, spacing and alignment for routability
 - ◆ ECOs for timing, signal integrity, reliability
 - ◆ Closely tied to performance analysis backplane (STA/PV)
 - ◆ Supports incremental “construct by correction” use model

Routing Directions

- Router ultimately responsible for meeting specs/assumptions
 - ◆ Slew, noise, delay, critical-area, antenna ratio, PSM-amenable ...
- Checks performability throughout top-down physical impl.
 - ◆ Actively understands, invokes analysis engines and macromodels
- Many functions
 - ◆ Circuit-level IP generation: clock, power, test, package substrate routing
 - ◆ Pin assignment and track ordering engines
 - ◆ “Monolithic” (entire net at a time) topology optimization engines
 - ◆ Owns key DOFs: small re-mapping, incremental placement, device-level layout resynthesis
 - ◆ Is hierarchical, scalable, incremental, controllable, well-characterized (well-modeled), detunable (e.g., coarse/quick routing), ...

Methodology Criteria/Directions

- Mixed-signal capability
 - ◆ Fully-hierarchical block-based SoC design
 - ◆ Timing, electrical design & verification
 - ◆ Power (current) distribution, electromigration
 - ◆ Concurrent engineering
- Functional design flexibility
 - ◆ Late-stage ECOs handled near tape-out
- Analog circuit design
 - ◆ System, chip, package, I/O optimization
 - ◆ Robust clock architecture
 - ◆ Verified crosstalk, Signal Integrity
- Technology readiness, electrical design experience
 - ◆ Validated, robust design margins → stable (high) yield
- Program management

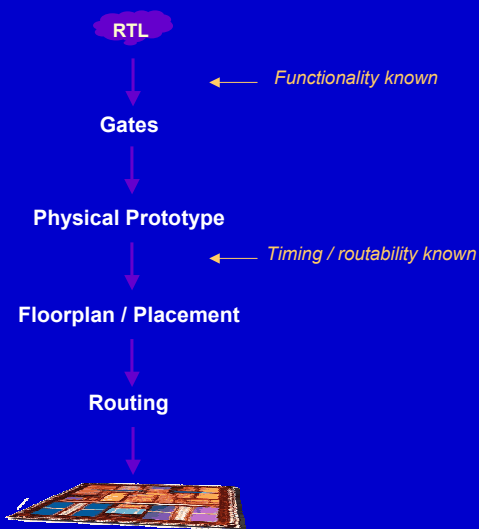
Notes on “Silicon Virtual Prototyping” and Convergence Methodologies

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“Physical Prototyping Philosophy”



- Prototype delivers accurate physical data
- Based on tape-out quality placement and ‘detail’ route
- Includes timing, clock tree and power analysis engine
- Hierarchical:
 - ◆ Chip-level CTS, top-level route and IPO, power analysis and grid design
 - ◆ Block-level synthesis, placement, IPO, routing
- “Handoff with enough physical information to ensure correct results”

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M. Courtoy, Silicon Perspective

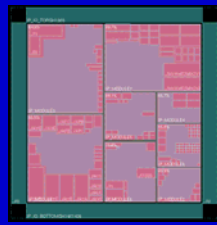
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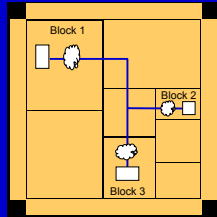
Coarse Placement Drives Partitioning, Coarse Routing Drives Pin Assignment / Timing Opt



Physical Prototype



Partitioning



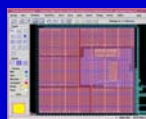
Block-Level Timing Budgets



Block-Level Pin Assignments

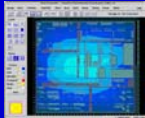
- Full-chip prototype results in optimal pin placement
 - ◆ Results in narrower channels and reduced die size
 - ◆ Reduces the routing congestion
 - ◆ Improves the chip timing
- Accurate timing budgets result in predictable timing convergence

Cool Pictures of the Pieces...



Full Chip Power Planning

Power IR Drop Analysis

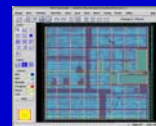


Partition

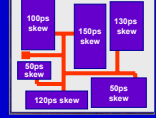


"Tape Out Every Day"

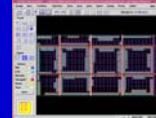
Timing Closure



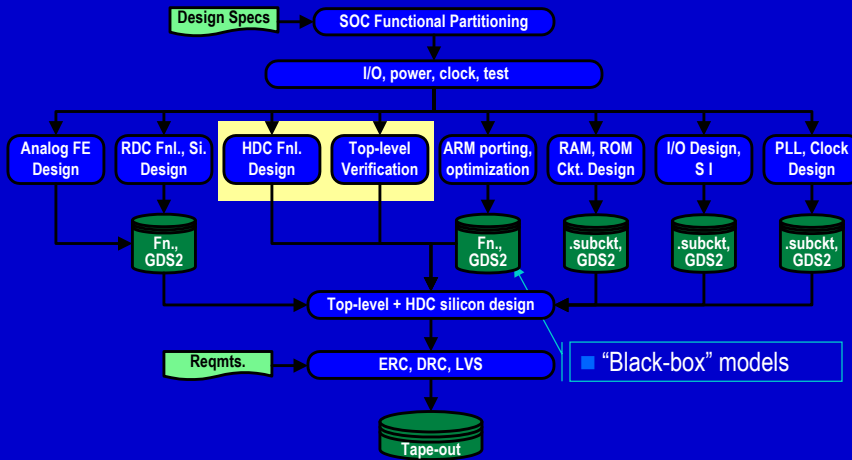
Hierarchical Clock Tree Synthesis



Block-Level Optimization

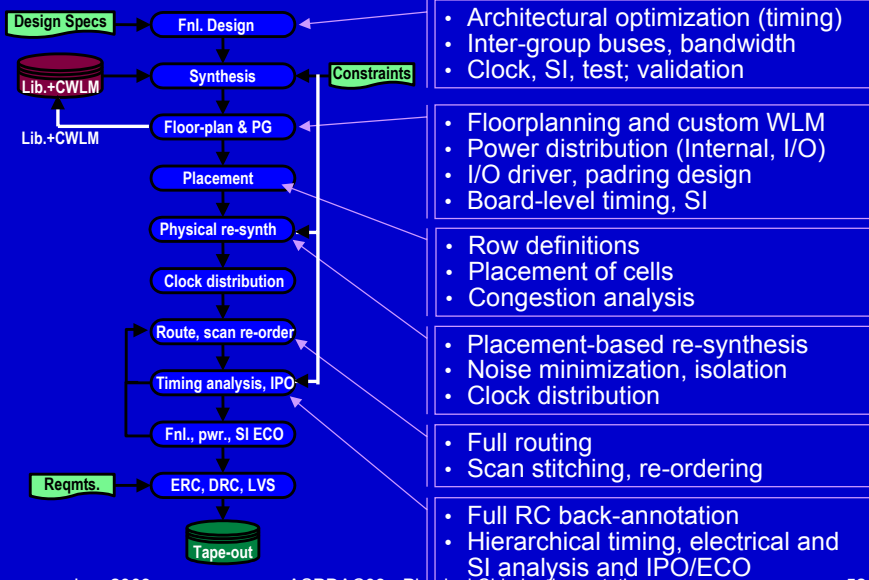


Top-Level Methodology

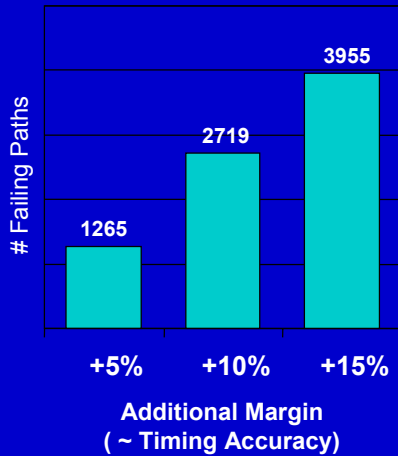


- Functional design → hierarchical
- Electrical / physical design → hierarchical
- IP leverage; Customer-specific design

Block-Level Methodology



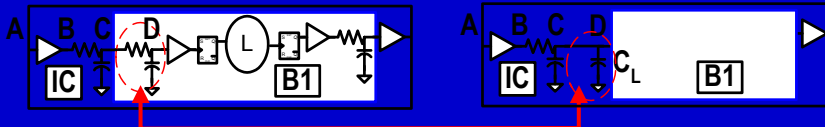
Issue: Accuracy vs. Margin



- Margin has costs
 - ◆ More failed paths
 - ◆ Additional engineering resources
 - ◆ Longer to tape-out
 - ◆ Missed market opportunity
- Lost revenues, business opportunity
- $.18\mu \rightarrow .13\mu \rightarrow .10\mu =$ more cross-coupling, lower Vdd (more IR risk)

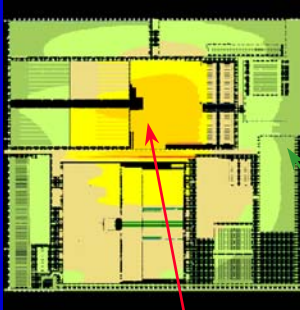
Issue: Hierarchical Analysis

- Fully-hierarchical block-based timing analysis
 - ◆ Analyze large designs (scalable capacity)
 - ◆ Enable concurrent design
 - ◆ Faster timing convergence, verification (STA)
- Signal paths traverse hierarchy
 - ◆ Block inputs with $\sim 0 - 2$ mm metal \rightarrow RC delay



- Model block boundary pin input RC as CL
- CL \rightarrow timing inaccuracies when RC significant

Issue: Power-Timing Interaction



- Buffers get different VDD voltage
- This and IR drops cause timing closure problems if not accounted for
 - ◆ Additional failed paths
 - ◆ Race conditions

